

ABSTRACT

The invention provides an electro-optic device that includes a frame (i.e., frame-shaped pattern) disposed on a frame area in a TFT array substrate. The frame area is disposed between an image display area and a peripheral area. The frame is formed of the same film as capacitor electrodes, and is disposed at at least a part of the frame area. The frame is formed of the same film as wiring connected to an external circuit-connecting terminal. Accordingly, the electro-optic device can prevent the generation of an image caused by light leakage at the periphery of the image as much as possible, and thereby improve image quality.